L Number	Hits	Search Text	DB	Time stamp
-	844	((423/240r,240s) or (588/248)).CCLS.	USPAT; US-PGPUB	2003/11/15 21:27
-	330	(423/240s).CCLS.	USPAT; US-PGPUB	2003/11/15 21:27
-	60	((423/240s).CCLS.) and (hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3)	USPAT; US-PGPUB	2003/11/15 21:28
-	161	((423/240s).CCLS.) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4)	USPAT; US-PGPUB	2003/11/15 21:29
-	56	(((423/240s).CCLS.) and (hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3)) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4)	USPAT; US-PGPUB	2003/11/15 21:36
-	2	((((423/240s).CCLS.) and (hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3)) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4)) and (cvd or (chemical adj vapor adj deposition))	USPAT; US-PGPUB	2003/11/15 21:34
-	3	("9930809").PN.	EPO; JPO; DERWENT; IBM_TDB	2003/11/15 21:35
-	803	(cvd or (chemical adj vapor adj deposition)) and ((hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/11/15 21:36
-	348	((cvd or (chemical adj vapor adj deposition)) and ((hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3))) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4)	USPAT; US-PGPUB	2003/11/15 21:39
-	1	(((cvd or (chemical adj vapor adj deposition)) and ((hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3))) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4)) and ("thermal-swing" or (thermal adj swing))	USPAT; US-PGPUB	2003/11/15 21:37
-	27	((cvd or (chemical adj vapor adj deposition)) and ((hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3))) and (hcl or hydrochloric or (hydrogen adj chloride)) with (vapor or gas$4) with (silane or $4osilane or halogenosilane)	USPAT; US-PGPUB	2003/11/15 21:39
-	11	((cvd or (chemical adj vapor adj deposition)) and ((hcl or hydrochloric or (hydrogen adj chloride)) with (separat$3 or recover$3 or obtain$3))) and (hcl or hydrochloric or (hydrogen adj chloride)) with (recover$3 or separat$3 or remov$3) with (silane or $4osilane or halogenosilane)	USPAT; US-PGPUB	2003/11/15 21:39